

Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
1	BRS	L1	TFT or (thin adj2 film adj2 transistors\$2)	USPA	2001/09/27 16:53			0
2	BRS	L2	144 (oxynitride or silicon adj Nitrogen adj oxygen or si adj n adj o) and (semiconductor adj film)	USPA	2001/09/27 16:53			0
3	BRS	L3	72 1 and 2	USPA	2001/09/27 16:44			0
4	BRS	L4	63380 (Nitrogen or N) with Concentrat\$4	USPA	2001/09/27 16:49			0
5	BRS	L5	18243 (silicon or Si) with Concentrat\$4	USPA	2001/09/27 16:50			0
6	BRS	L6	49142 (oxygen or o) with Concentrat\$4	USPA	2001/09/27 16:50			0
7	BRS	L7	18 1 and 2 and 4 and 5	USPA	2001/09/27 16:44			0
8	BRS	L8	10 1 and 2 and 4 and 5 and 6	USPA	2001/09/27 17:32			0
9	BRS	L9	502 TFT or (thin adj2 film adj2 transistors\$2)	US-P GPUB	2001/09/27 16:48			0
10	BRS	L10	20 (oxynitride or silicon adj Nitrogen adj oxygen or si adj n adj o) and (semiconductor adj film)	US-P GPUB	2001/09/27 16:48			0
11	BRS	L11	18 9 and 10	US-P GPUB	2001/09/27 16:49			0
12	BRS	L12	708 (Nitrogen or N) with Concentrat\$4	US-P GPUB	2001/09/27 17:05			0
13	BRS	L13	14 9 and 10 and 12	US-P GPUB	2001/09/27 16:50			0

Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
14	BRS	L14	359 (silicon or Si) with concentrat\$4	US-P GPU	2001/09/2 7 17:06			0
15	BRS	L15	9 9 and 10 and 12 and 14	US-P GPU	2001/09/2 7 16:51			0
16	BRS	L16	434 (oxygen or o) with concentrat\$4	US-P GPU	2001/09/2 7 17:06			0
17	BRS	L17	7 9 and 10 and 12 and 14 and 16	US-P GPU	2001/09/2 7 16:51			0
18	BRS	L18	1953 TFT or (thin adj2 film adj2 transistor\$2)	EPO	2001/09/2 7 17:27			0
19	BRS	L19	1 (oxynitride or silicon adj Nitrogen adj oxygen or si adj n adj o) and (semiconductor adj film)	EPO	2001/09/2 7 16:54			0
20	BRS	L20	0 18 and 19	EPO	2001/09/2 7 16:53			0
21	BRS	L21	0 Silicon adj2 Nitrogen adj2 oxygen or si adj2 n adj2 o) and (semiconductor adj film) and 18	EPO	2001/09/2 7 16:55			0
22	BRS	L22	11402 TFT or (thin adj2 film adj2 transistor\$2)	JPO	2001/09/2 7 17:15			0
23	BRS	L23	4 (oxynitride or silicon adj2 Nitrogen adj2 oxygen or si adj2 n adj2 o) and (semiconductor adj film)	JPO	2001/09/2 7 16:59			0
24	BRS	L24	2 22 and 23	JPO	2001/09/2 7 16:55			0

Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
25	BRS	L25	13245 TFT or (thin adj2 film adj2 transistor\$2)	DERW ENT	2001/09/2 7 17:07			0
26	BRS	L26	3 (oxynitride or silicon adj2 Nitrogen adj2 oxygen or si adj2 n adj2 o) and (semiconductor adj film)	DERW ENT	2001/09/2 7 17:01			0
27	BRS	L27	0 25 and 26	DERW ENT	2001/09/2 7 17:01			0

Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
30	BRS	L31 0	25 and 30	DERW ENT	2001/09/2 7 17:03			0
31	BRS	L30 5	(ox\$nitride or oxinitride or silicon adj2 Nitrogen adj2 oxygen or si adj2 n adj2 o) and (semiconductor adj film)	DERW ENT	2001/09/2 7 17:03			0
32	BRS	L32 8618	(Nitrogen or N) with concentrat\$4	DERW ENT	2001/09/2 7 17:14			0
33	BRS	L33 3426	(silicon or Si) with concentrat\$4	DERW ENT	2001/09/2 7 17:14			0
34	BRS	L34 8369	(oxygen or O) with concentrat\$4	DERW ENT	2001/09/2 7 17:14			0
35	BRS	L35 4	32 and 33 and 34 and 25	DERW ENT	2001/09/2 7 17:07			0
36	BRS	L36 11753	(Nitrogen or N) with concentrat\$4	JPO	2001/09/2 7 17:27			0
37	BRS	L37 6425	(silicon or Si) with concentrat\$4	JPO	2001/09/2 7 17:27			0
38	BRS	L38 10968	(oxygen or O) with concentrat\$4	JPO	2001/09/2 7 17:27			0
39	BRS	L39 0	22 and 36 and 3	JPO	2001/09/2 7 17:16			0
40	BRS	L40 7	22 and 36 and 37 and 38	JPO	2001/09/2 7 17:16			0
41	BRS	L41 2508	(Nitrogen or N) with concentrat\$4	EPO	2001/09/2 7 17:27			0
42	BRS	L42 1004	(silicon or Si) with concentrat\$4	EPO	2001/09/2 7 17:27			0
43	BRS	L43 9353	(oxygen or O) with concentrat\$4	EPO	2001/09/2 7 17:27			0
44	BRS	L44 4	18 and 41 and 42 and 43	EPO	2001/09/2 7 17:28			0
45	BRS	L45 150	1 and 4 and 5 and 6	USPA T	2001/09/2 7 17:32			0